SEKISUI CHEMICAL CO., LTD.



Electronics Field Briefing

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High Performance Plastics Company
Head of Electronics Business Strategy Department

August 26, 2025

Agenda

- 1. SEKISUI CHEMICAL Profile
- 2. HPP Company Overview
- 3. Electronics Field Overview
- 4. Market Overview and Trends
- 5. Overview of Key Products
- 6. Technology Platform (TPF) Activities and Research & Development
- 7. Research & Development, Investment Plan

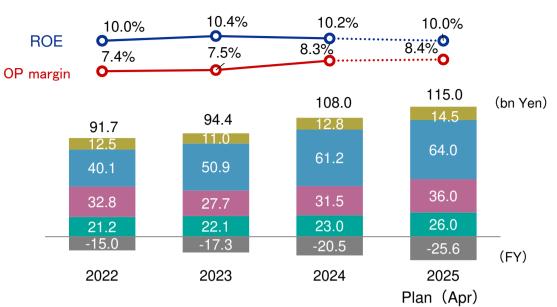
8. Our Vision

1. SEKISUI CHEMICAL Profile



	As of March 31, 202
March 3	1947

Founded	March 3, 1947
Number of employees	26,918
Consolidated subsidiaries	145
Affiliates (Equity Method)	6
Consolidated net sales	1,297.8 bn Yen (FY24)
Consolidated operating profit	108.0 bnYen (FY24)
Number of shares outstanding	440,507,285 shares



Segment Information

High Performance Plastics Company (HPP)

Leveraging our proprietary fine particle, adhesion, precise molding, and other technologies, we provide advanced high-performance materials for application in the Electronics, Mobility and industrial fields.

Housing Company

We engage in new housing construction as a specialist in the Unit Construction Method, an advanced factory-built approach that enables short construction periods and delivers functions in accordance with design plans.

Urban Infrastructure & Environmental Products Company (UIEP)

Under the theme of an environment-solution company, we are developing our business centered on next-generation infrastructure to help realize a more affluent and safe society.

Medical Business

Our goal is to continuously help improve the quality of life and well-being of people worldwide through products, systems, and services that contribute to healthcare advancements.

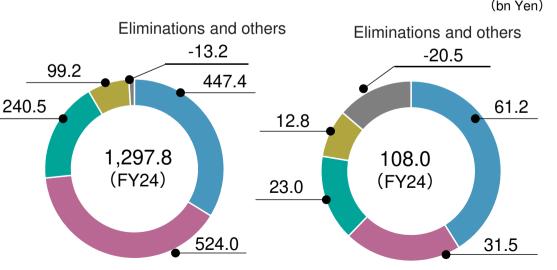
Other

In addition to corporate expenses, Other includes expenses related to new businesses, R&D, lithium-ion batteries for stationary use, SEKISUI BIO REFINERY CO., LTD., perovskite solar cells, etc.

Breakdown of Sales

Breakdown of Operating Profit

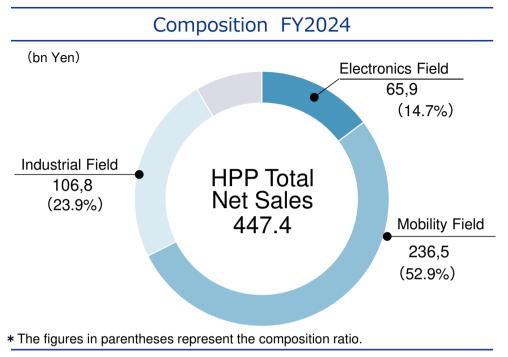
(bn Yen)

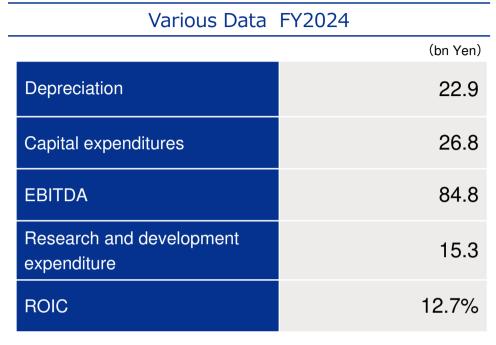


2. High Performance Plastics (HPP) Company Overview



FY23=100





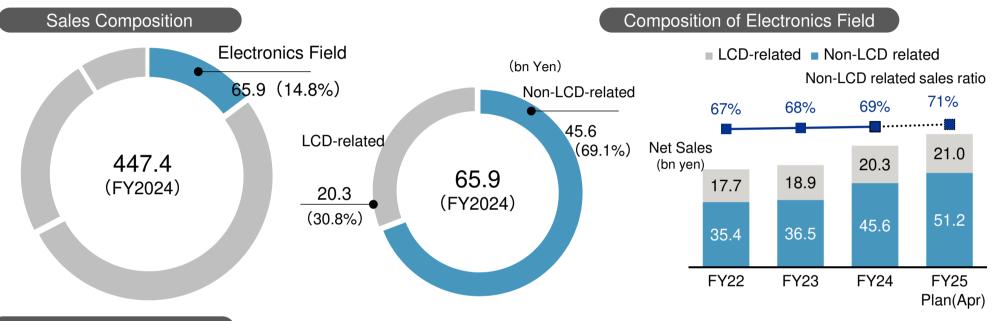
Three Strategic Fields

Mobility Field Industrial Field **Electronics Field** (bn yen) (bn yen) (bn yen) 108% 119% 108% 100% 100% 100% 259.1 110.8 72.1 106.8 236.5 65.9 219.1 98.6 55.4 FY23 FY24 FY23 FY24 FY25 FY23 FY25 FY24 FY25 Plan(Apr) Plan(Apr) Plan(Apr)

3. Electronics Field Overview



Broadly speaking, the electronics field can be divided into two areas: non-LCD-related and LCD-related. These are further classified into four product categories: semiconductors/electronic components, exterior/mechanical components, next-generation displays, and LCD displays.



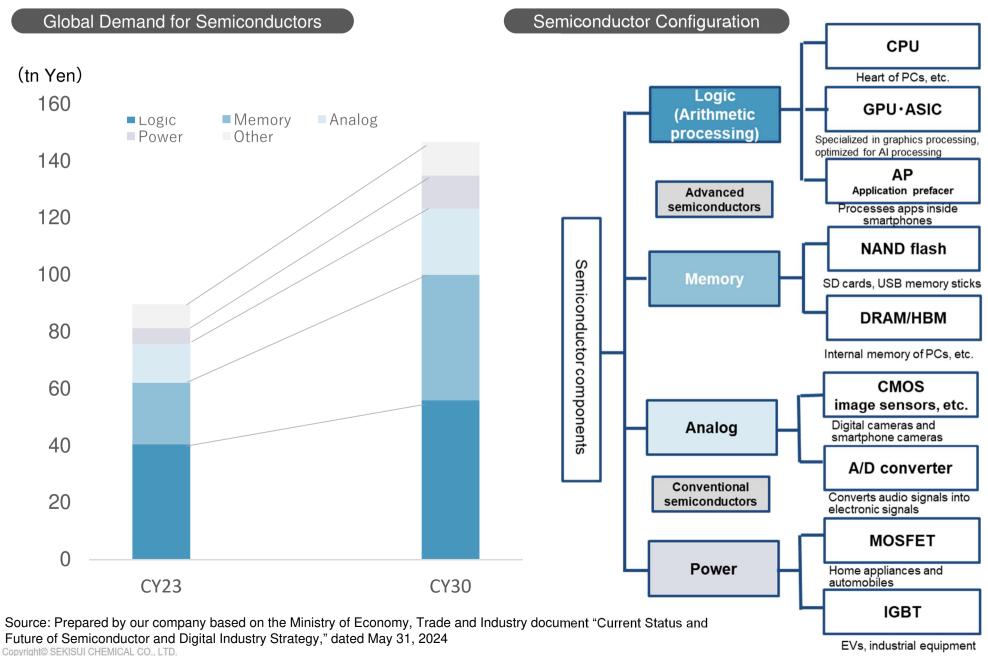
Product Configuration

Field		Main products	Main applications		
Semiconductors/ electronic	UV peeling off tape	Semiconductor manufacturing process			
	Binder resin	MLCC manufacturing process			
Non-LCD-		Heat release materials	Servers, base stations		
related	related Exterior/mechanical components Next-generation displays	Functional foam tape	TVs, smartphones		
		µLED sealing material	mini/μLED		
LCD-related	LCD displays	Microparticles, spacers, sealants Tapes, films	LCD displays		

Global Demand for Semiconductors and 4. Market Overview/Trends: Semiconductor Overview



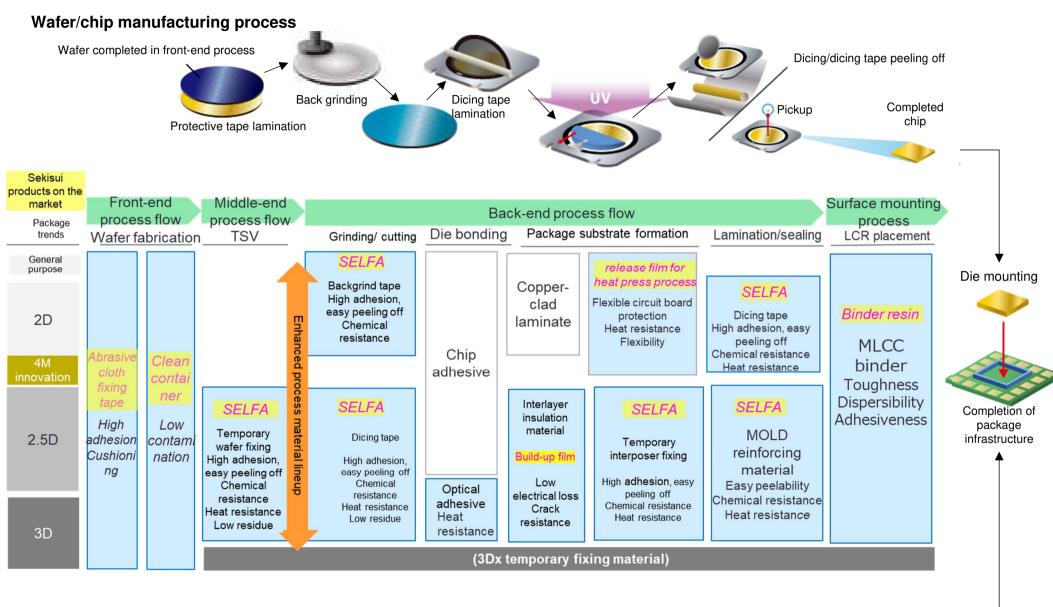
■ The global semiconductor market is expected to see high growth until 2030, driven by advanced semiconductors for generative AI, automobiles, and high-performance devices.



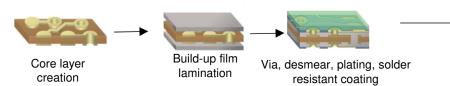
Semiconductor Component Manufacturing Process and Our Products



Semiconductor Manufacturing Process



Package substrate manufacturing process



6

4. Market Overview/Trends: Semiconductor-related Trends



Semiconductor-related Trends

Semiconductor trends

Package trends

Spread of smartphones

General purpose

High speed and high capacity (thin chips/laminated substrates)

2D

Innovation areas in 4M (materials, equipment, methods, and people) (Emergence of highly difficult technical issues)

Spread of Al

Low power consumption (low power loss design) Large glass substrates/ photoelectric fusion

2.5D

Multifunctionality Power saving (Hybrid bonding)

3D

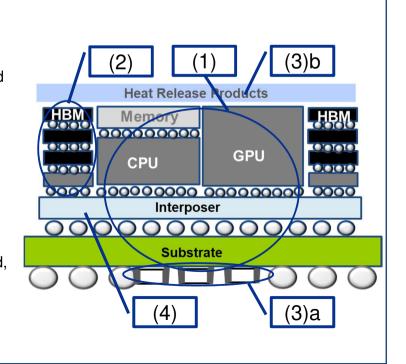
The latest package trends in advanced semiconductors show a move toward higher speeds, larger capacities, and wider bandwidths. Consequently, the mounting process is becoming increasingly complex, progressing from 2D to 2.5D to 3D, and there is a growing need for materials, equipment, processes, and operating methods that can respond to these changes.

■ 2D package

- > FOWLP
 - Support material applicable to various device structures
 - Heat release materials that efficiently dissipate heat from hot spots

Next-generation semiconductor elements

- (1) 2.5D package
 - > GPU/ASIC
 - Interposers/Materials with easy peelability suitable for large-size substrates
 - Low dielectric insulation materials required for larger sizes/higher speeds
- (2) 3D package
 - **≻** HBM
 - Materials with thermal resistant & easy peelability required for the evolution from HBM2→3→4
- (3) High performance
 - a Increased number of MLCCs installed for stable power supply
 - b High heat release required for high-speed, large-capacity processing
- (4) High-density mounting
 - > Hybrid bonding
 - Ultra-low residue peelability materials required for lamination and 3D modeling



5. <Semiconductor/Electronic Components> UV Peeling Off Tape SELFA™





Product Features

 UV peeling off tape that combines heat resistance, chemical resistance, high adhesion, and easy peelability

Competing Technology

· Liquid materials

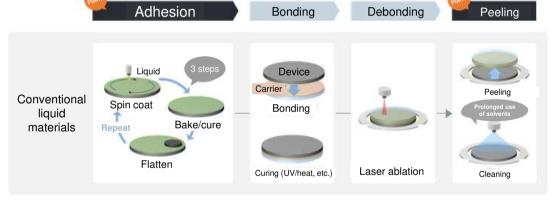
Glass carrier

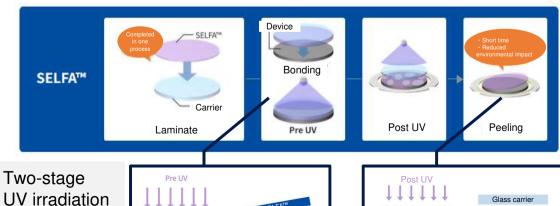
Wafer

Generation of N2 gas by UV irradiation Wafer

Peeling after gas

Process Comparison





Wafer

Peeling after curing

Curing the adhesive layer with UV irradiation

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Strengths

Heat resistance: up to 220°C heat resistant specification (up to 260°C CW)

Easy-to-peel: Damage-free peeling using gas generation peeling technology

Suitable for ultra-thin devices

Low residue: Residue-free thanks to Pre UV technology

Applications

- CMOS image sensors
- High Bandwidth Memory (HBM)

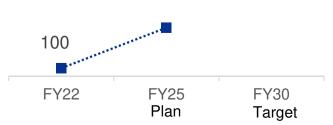


Application processors (FOWLP)



Communication modules (SiP), etc.

Sales growth rate (FY22=100)



5. <Semiconductor/Electronic Components> Interlayer Insulation Film (Build-up Film) 5 (KIS)





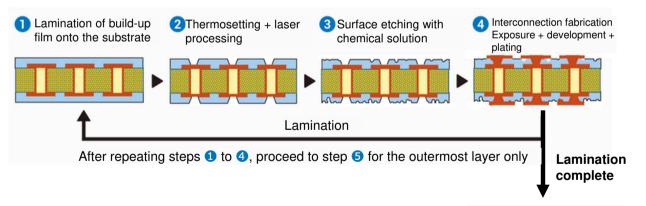
Product Features

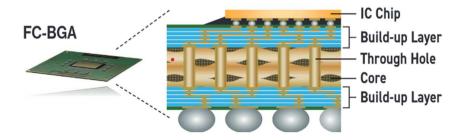
- Insulating film used in semiconductor package substrates
- Required features: SAP process suitability, reliability, and functional characteristics
- One of only a handful of build-up film providers

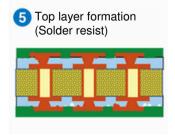
Strengths

- Package substrates are becoming larger and multi-lavered.
 - Responds to increased communication loss, crack problem, and low yield rates
- > Low dielectric design: Contributes to low communication loss
- Low internal stress design: Contributes to high reliability
- High processability design: Excellent SAP processability

Processing Process (SAP process)







Applications

Semiconductor package substrates requiring low latency and low power consumption

- Conventional FCBGA (Flip Chip-Ball Grid Array)
- Next-generation package (2.xD)
 - > High-performance CPU (PC, server)
 - > GPU
 - > Al and network equipment processors, etc.





5. <Semiconductor/Electronic Components> Heat Release Products



Heat Release Grease





Product Features

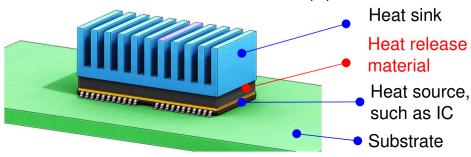
- Two-component room temperature solidifying heat release grease
- Excellent stability of physical and electrical properties over a wide temperature range
- Highly flexible, reducing stress caused by differences in thermal expansion
- A range of grades with different thermal conductivity and hardness

Strengths

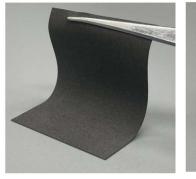
- Achieves flexibility and high thermal conductivity through unique resin design and filler dispersion
- · Outstanding handleability and automatic coating properties

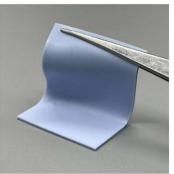
Applications

Heat countermeasures for high-load equipment, such as batteries, power devices, and semiconductor-related equipment



Heat Release Sheet





Product Features

- · High heat resistance and flexibility
- Contains low levels (≤70 ppm) of low-molecular-weight cyclic siloxanes, known to cause contact failure
- Wide lineup (insulated type, high heat conduction type, radio wave absorption type, etc.)

Strengths

- Utilizes unique filler orientation technique to achieve high thermal conductivity while maintaining flexibility
- Achieves ultra-low thermal resistance through thin film technology



5. <Semiconductor/Electronic Components> High-viscosity Inkjet Ink







Product Features

- No mask required, optional shape printing possible
- Printing on uneven substrates possible
- Reduces processes and material usage

Strengths

Stable coating of high-viscosity materials and proprietary printing process enabling:

- Shape flexibility (3D)
- High functionality (high heat resistance and strength)

Applications

For coating (barrier rids)

Purpose: Warp prevention and surface protection Feasible for coating at the substrate edges



For sealing

Purpose: Protection
Printable in designated areas





For buffer layer

Purpose: Stress dispersion Crack suppression due to thermal expansion differences in dissimilar material bonding Printable in designated areas



For adhesion

Purpose: Adhesion of dissimilar materials Printable in designated areas Printable on cavities

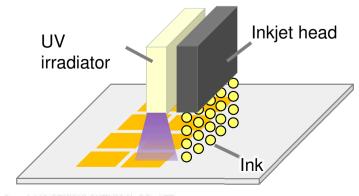


Comparison with other printing methods

Printing method	Resolution	Height	Process time
Sekisui inkjet	0	0	0
Regular inkjet	×	×	0
Dispenser	×	0	×

Expected to be adopted in the second half of 2025 for mobile device mechanical parts, camera modules, semiconductor packages, Al servers, etc. Expected to expand from FY2026.

Process



Wall materials



Step shape



Inclined shape



Cylindrical shape



Sales growth rate (FY22=100)



5. <Semiconductor/Electronic Components> Release Film for Heat Press Process **SEKIS**





Product Features

Special polyester layer

Multi-layer structure consisting of a special polyester layer and polyolefin cushioning layer, widely used for surface protection and cushioning in heat press process

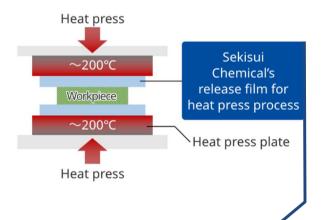
Polyolefin cushioning layer

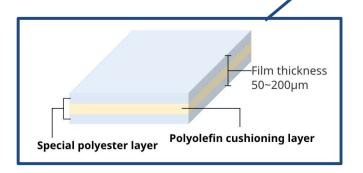
- Withstands heat press at a wide range of temperatures and can be easily removed from the workpiece after pressing (Polyolefin cushioning layer)
- Easy to deform and conform to the shape of the workpiece

Strengths

- Heat resistance: Resistant to heat and can be used at high temperatures (approx. 50 to 200°C)
- Flexibility (shape conformability): Deforms softly without wrinkling
- Surface protection/cleanness
- Protects surfaces without contaminating the workpiece with low outgassing and low transfer
- Free from silicone and PFAS

Multi-layer Structure of the Release Film





Applications

Surface protection during heat press in substrate ma3nufacturing

- Surface protection for flexible printed circuit (FPC) manufacturing
- Surface protection during rigid-flex board manufacturing

Heat resistance/cushioning

- · Semiconductor mold forming
- CFRP manufacturing
- Chips: Heat and pressure cushioning during ACF bonding
- Other: Protection and cushioning during heat press process



Sales growth rate (FY22=100)





Product Features

- Polyvinyl Acetal Resin is composed of three units: acetal group, acetyl group and hydroxyl group.
- Polyvinyl acetal resin (PVB) with excellent physical properties: Toughness, Adhesiveness and Dispersibility

Strengths

Toughness: Is flexible with moderate strength Dispersibility: Maintains fine and uniform dispersion as a dispersing agent Adhesiveness: Bonds sheets together firmly as a binder

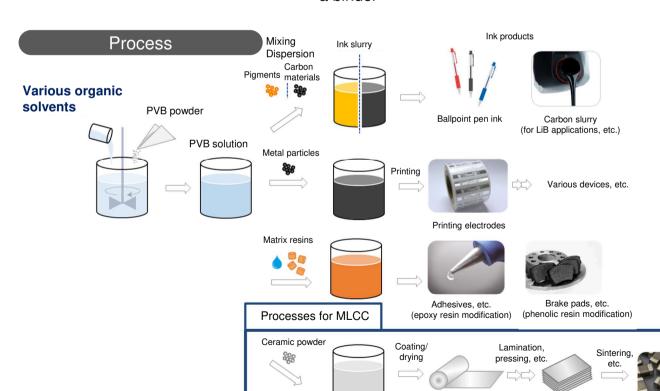
Green sheet

Laminated body

MLCC, etc.

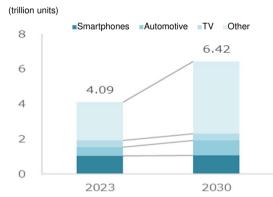
Applications

- Various ceramic binders centered on MLCC
- Binders for conductive pastes
- Dispersants for pigments, carbon materials, etc.
- Modifiers (high-performance agents) for epoxy and phenolic resins
- · Inkjet receptive layers, adhesives etc.



Ceramic slurry

MLCC Global Demand



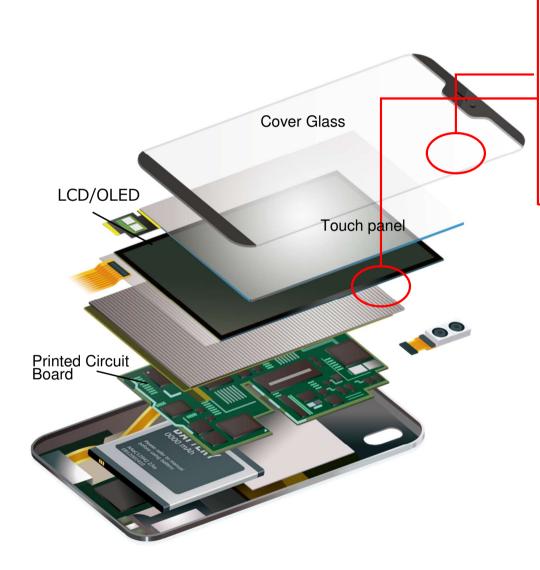
Source: Fuji Chimera Research Institute, Inc., 2024: Current Status and Future Prospects of Advanced Materials for Electronics

Sales growth rate (FY22=100)



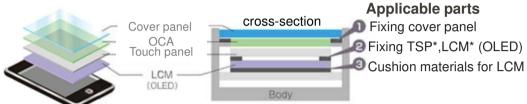
5. <Exterior Parts/Mechanism Components>





Exterior Parts/Mechanism Components

- Functional foam tape
 - Fixing cover glass and flame / Absorbing drop impact



*TSP: Touch Sensor Panel

*LCM: Liquid Crystal Module

- **Elastic resin Photolec B**
 - Contributing to the production automation of component fixing through UV – temporary curing + moisture curing
- Conductive fine particles Micropearl™
- High-viscosity Inkjet Ink
- Thin foam XLIM
 - Cushioning material for impact protection of display panels and various components



5. < Display Components > LCD/Next Generation Display

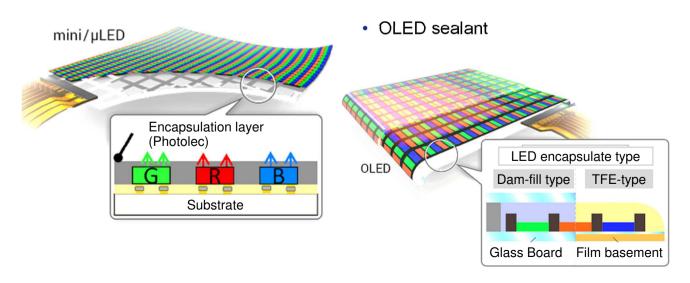


Product Lin	eup for	FPD
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	Product Features	Our strengths	Share
UV Adhesive (Adhesive for LCD Panels)	 UV adhesives made of high-performance, high- purity resins with exceptional ultraviolet-curing properties. 	Less likely to contaminate LCDsCapable of applying fine lines	Top Global Market Share
LCD Spacer	Pearl-like plastic spheres of several-micron diameter maintain a constant liquid crystal layer thickness	 Uniform particle size distribution Heat, voltage, and chemical resistance 	Top Global Market Share *Shares are calculated based on our estimate
Conductive Fine Particles	 Fine particles with electrical conductivity on gold- plated plastic spheres. Display images are produced by electric voltage flowing through the fine particles. 	 Uniform particle size distribution Uniform metal layers Can form various metal layers More flexible than metal particles 	Top Global Market Share

Next Generation Display

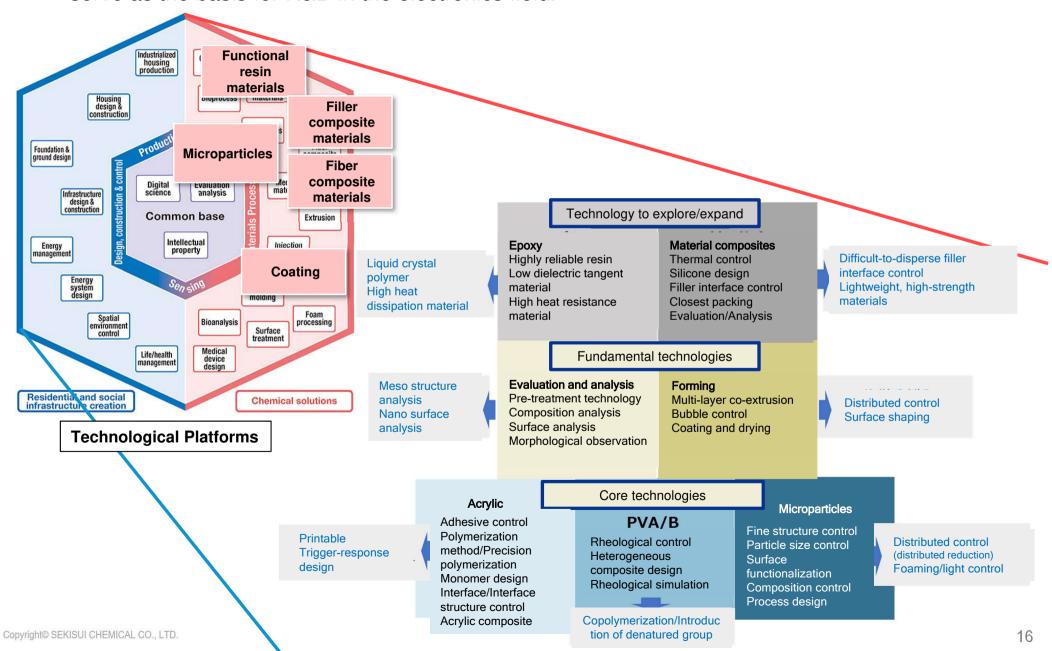
- µLED sealing material:
 - Solvent-free sealing material that hardens with UV light alone
 - ➤ High hardness (glass substitute)
 - Flexible (flexible substrates compatible)
- UTG protective resin Photolec[™] New



6. Technology Platform (TPF) Activities and Research & Development

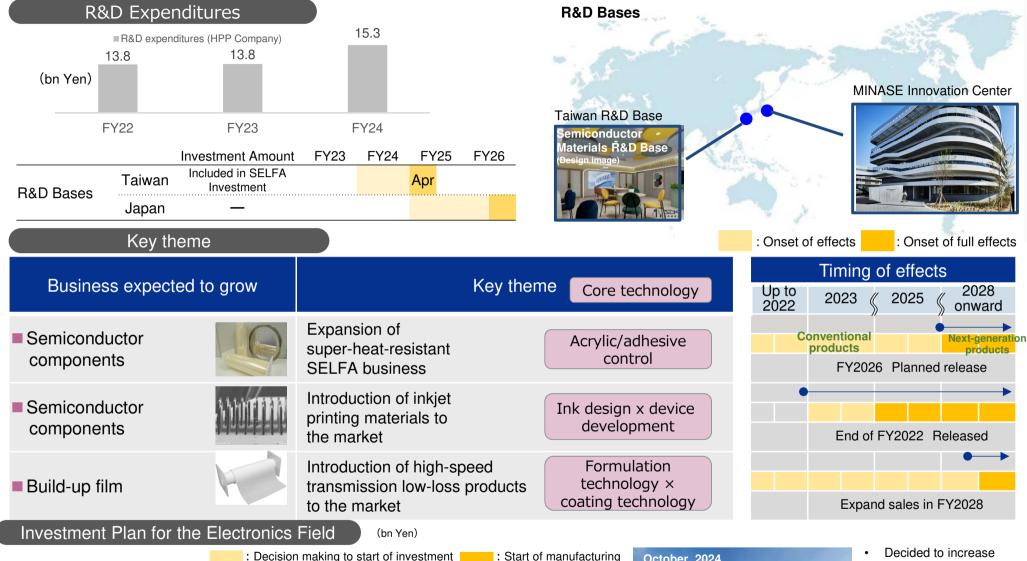


Strengthen, explore, and expand core and fundamental technologies in the fields of microparticles, coating, functional resin materials, filler composite materials, and fiber composite materials, which serve as the basis for R&D in the electronics field.



7. Research & Development, Investment Plan





1H

		. Decision i	. Start of manufacturing				nanulaciumiy	
Products		Investment Amount	FY23	FY24	FY25	FY26	FY27	FY28
SELFA	Japan	5.0 Including Taiwan R&D Base expenses					1H	
PVB	Japan	2.0				1Q		

2.0

October, 2024

Decided to increase production capacity of conductive fine particles

Taga Plant

Decided to increase production capacity of Micropearl AU®, conductive fine particles used in circuit connections for displays and mechanical components
 Plan to start operations in

the first half of FY2028

Also expand to next-generation displays such as μ LED and automotive applications

Japan

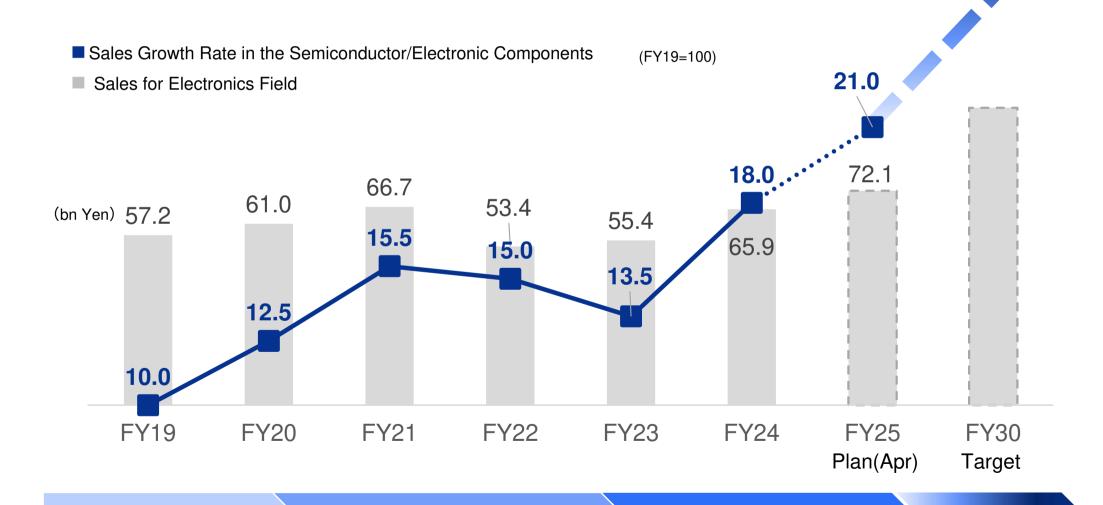
Conductive fine

particles

8: What We Aim to Achieve



We aim to double our business volume compared to 2019, with the semiconductor/electronic components segment as the growth driver. We will seek to further enhance our presence as a high-performance plastics company.



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Drive 2.0

Drive 2022



This slide presentation contains forward-looking statements.

These statements are based on current expectations and beliefs. However, actual results may differ from those expressed or implied due to a number of factors and uncertainties such as changes in the global economy and our business, competition in the market, and regulatory issues.

Note: Figures denominated in units of 100 million JPY are rounded off to the nearest hundred million.

